

**IN THE CLAIMS**

The following is a listing of the claims in the application with claim 1 shown as amended and with claim 7 cancelled:

**LISTING OF CLAIMS**

1. (currently amended) An organic mold for transferring micropatterns to a substrate, the organic mold having a reverse pattern face of the face of said micropatterns and being fabricated from a resin composition comprising:
  - (A) 40 to 90 parts by weight of an active energy curable urethane- based oligomer having a reactive group selected from the group consisting of (meth)acrylate, vinyl ether, arylether, and a combination thereof;
  - (B) 10 to 60 parts by weight of a monomer reactive with the urethane- based oligomer, having a reactive group selected from the group consisting of (meth)acrylate, vinyl ether, arylether, and a combination thereof;
  - (C) 0.01 to 200 parts by weight of a silicone or fluorine containing compound, based on 100 parts of the sum of the components (A) and (B); and
  - (D) 0.1 to 10 parts by weight of a photoinitiator, based on 100 parts of the sum of the components (A), (B) and (C).

wherein the silicone- or fluorine-containing compound is at least one component selected from:

(i) a silicone-containing reactive monomer or oligomer selected from the group consisting of a silicone-containing vinyl derivative, silicone-containing (meth)acrylate, (meth)acryloxy-containing organosiloxane silicone polyacrylate, and a mixture thereof;

(ii) a fluorine-containing reactive monomer or oligomer selected from the group consisting of a fluoroalkyl-containing vinyl derivative, fluoroalkyl-containing (meth)acrylate, fluorine polyacrylate, and a mixture thereof; and

(iii) a combination of (i) and (ii).

2. (previously amended) The organic mold according to claim 1, wherein the active energy curable urethane-based oligomer used in the resin composition is selected from the group consisting of linear aliphatic, cycloaliphatic and aromatic urethane-based oligomers having at least two reactive groups, and a mixture thereof.

3. (previously amended) The organic mold according to claim 1, wherein the resin composition further comprises at least one reactive oligomer selected from the group consisting of a (meth)acrylated polyester, (meth)acrylated polyether, (meth)acrylated epoxy, (meth)acrylated polycarbonate, (meth)acrylated butadiene,

and a mixture thereof, as a partial substituent of Component A.

4. (previously amended) The organic mold according to claim 1, wherein the (meth)acrylate used as Component B in the resin composition is selected from the group consisting of isobomyl acrylate, 1,6- hexanediol acrylate, triethyleneglycol di(meth)acrylate, trimethylol propane triacrylate, tetraethyleneglycol di(meth)acrylate, 1,3-butanediol diacrylate, 1,4- butanediol diacrylate, diethyleneglycol diacrylate, neopentylglycol diacrylate, neopentylglycol di(meth)acrylate, polyethyleneglycol di(meth)acrylate pentaerythritol triacrylate, dipentaerythritol (hydroxy) pentaacrylate, alkoxylated tetraacrylate, octadecyl acrylate, isodecyl acrylate, lauryl acrylate, stearyl acrylate, behenyl acrylate, styrenic monomer, and a mixture thereof.

5. (previously amended) The organic mold according to claim 1, wherein the vinyl ether used as Component B in the resin composition is selected from the group consisting of cyclohexyl vinyl ether, 2-ethylhexyl vinyl ether, dodecyl vinyl ether, 1,4-butanediol divinyl ether, 1,4 hexanediol divinyl ether, diethylene glycol divinyl ether, ethyleneglycol buty vinyl ether, ethyleneglycol divinyl ether, triethyleneglycol methylvinyl ether triethyleneglycol divinyl ether, trimethylol propane trivinyl ether, 1,4 cyclohexane dimethanol divinyl ether, and a mixture thereof.

6. (previously amended) The organic mold according to claim 1, wherein the aryl ether used as Component B in the resin composition is selected from the group consisting of aryl propyl ether, ary butyl ether, pentaerythritol triary ether, and a mixture thereof.

7. (Cancelled).

8. (previously amended) The organic mold according to claim 1, wherein the photoinitiator used in the resin composition is a free radical initiator selected from the group consisting of benzyl ketals, benzoin ethers, acetophenone derivatives, ketoxime ethers, benzophenone, benzo and thioxantone compounds, and mixtures thereof, and a cationic initiator selected from the group consisting of onium salts, ferrocenium salts, diazonium salts, and mixtures thereof.

9. (previously amended) A method for fabricating an organic mold, which comprises coating or casting a resin composition for the organic mold on a pattern face of a mastermold, placing a support on the resin layer, irradiating the resulting laminate with an active energy ray to preliminarily cure the resin composition, lifting off the organic mold having a reverse pattern face to that of the mastermold and integrally formed with the support from the mastermold, and completely curing the organic mold wherein the resin composition comprises:

(A) 40 to 90 parts by weight of an active energy curable urethane-based oligomer having a reactive group selected from the group consisting of (meth)acrylate, vinyl ether, arylether, and a combination thereof;

(B) 10 to 60 parts by weight of a monomer reactive with the urethane-based oligomer, having a reactive group selected from the group consisting of (meth)acrylate, vinyl ether, arylether, and a combination thereof; and

(C) 0.01 to 200 parts by weight of a silicone or fluorine containing compound, based on 100 parts of the sum of the components (A) and (B).

10. (original) The method according to claim 9, which further comprises adhering a soft or rigid backing having a curved or flat face to the bottom face of the organic mold.

11. (previously amended) A method for fabricating an organic mold, which comprises coating or casting a resin composition for the organic mold on a pattern face of a master mold, irradiating the resin layer with an active energy ray to preliminarily cure it, pouring a UV- or heat-curable resin composition onto the cured resin layer as a backbone, heating or irradiating the resultant to completely cure the resin and the backbone layers, lifting off the organic mold having a reverse pattern face to that of the master mold and integrally formed with the backbone layer from the master mold, and completely curing the organic mold wherein the resin composition comprises:

- (A) 40 to 90 parts by weight of an active energy curable urethane- based oligomer having a reactive group selected from the group consisting of (meth)acrylate, vinylether, arylether, and a combination thereof;
- (B) 10 to 60 parts by weight of a monomer reactive with the urethane- based oligomer, having a reactive group selected from the group consisting of (meth)acrylate, vinylether, arylether, and a combination thereof;
- (C) 0.01 to 200 parts by weight of a silicone or fluorine containing compound, based on 100 parts of the sum of the components (A) and (B) and
- (D) 0.1 to 10 parts by weight of a photoinitiator, based on 100 parts of the sum of the components (A), (B) and (C).